



Super High Vertical Resolution Non-Contact 3D Surface Profiler  
BW-S500/BW-D500 Series

# BW-S500

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# BW-D500 Series



# Nikon's proprietary scanning-type optical interference measurement technology achieves **1pm\*** height resolution.

\* Height resolution specified by algorithm

Quickly and accurately measures surface profile from sub-nano to millimeter height ranges, using a single measurement mode. Fully supports high-precision processing technology and advanced material development of the Materials Science field.

## 4.19 Mpixel camera type

# BW-S500 Series

BW-S501/BW-S502/BW-S503/BW-S505/BW-S506/BW-S507

- Effective height resolution** 15 pm (including environmental noise)
- Measurement speed** 16 seconds (1022x1022 pixel mode, 10µm scanning)
- 38 seconds** (2046x2046 pixel mode, 10µm scanning)

General-purpose model with high-pixel resolution that measures both smooth and rough surfaces. Delivers super high-resolution height measurement with 4.19 Mpixel high-resolution camera.



## 2000 fps high speed camera type

# BW-D500 Series

BW-D501/BW-D502/BW-D503/BW-D505/BW-D506/BW-D507

- Effective height resolution** 15 pm (including environmental noise)
- Measurement speed** 4 seconds (510x510 pixel mode, 10µm scanning)

With its high-speed and high-precision, this model is suited for measurements of smooth surfaces such as glass and wafers. Delivers with a 2000 fps high-speed camera.



## Six models available to match application and cost

Both the BW-S and BW-D are available in the six types shown below.

	Piezo driven		Scanning			
	Objective lens drive	Nosepiece drive	Z axis		XY axis	
			Manual	Electric	Manual	Electric
BW-S501/D501	○		○		○	
BW-S502/D502	○			○	○	
BW-S503/D501	○			○		○
BW-S505/D505		○	○		○	
BW-S506/D506		○		○	○	
BW-S507/D507		○		○		○

### Electric Z axis

502/503/506/507

Enables measurement of steps in excess of 100µm (piezo scanning range).



### Electric XY axis

503/507

Enables wide-area analysis through the stitching of multiple height images.



### Nosepiece drive piezo

505/506/507

Allows easy switching of objective lens magnification.



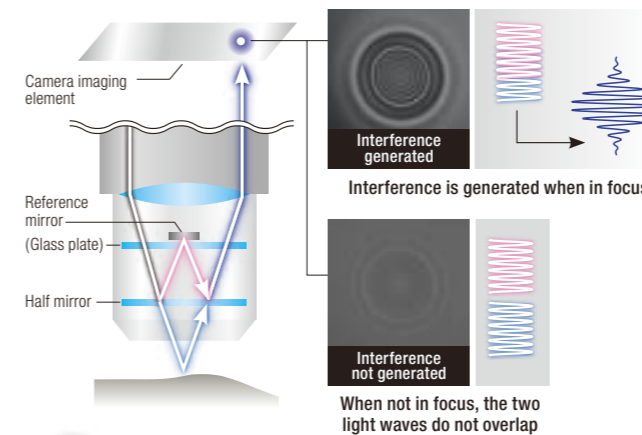
\* An affordable objective lens drive piezo is also available.

## High-precision/high-speed image acquisition via a two beam interference objective lens

The BW-S500 / D500 series uses a two beam interference objective lens and Nikon's proprietary algorithms to acquire height images with high speed and precision.

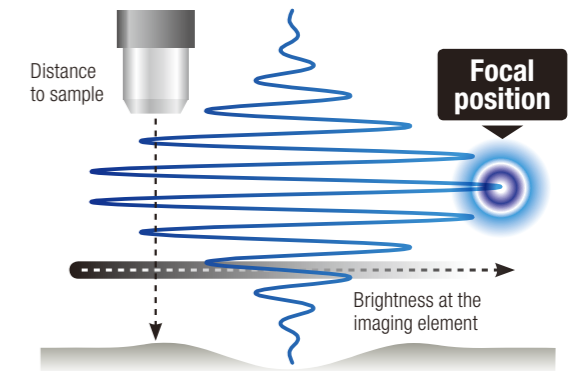
### 1 Interference created by two beam interference objective lens

By overlaying the light returning from the reference mirror inside the objective lens and the light returning from the sample, the two beams overlap at the focal position and create interference.



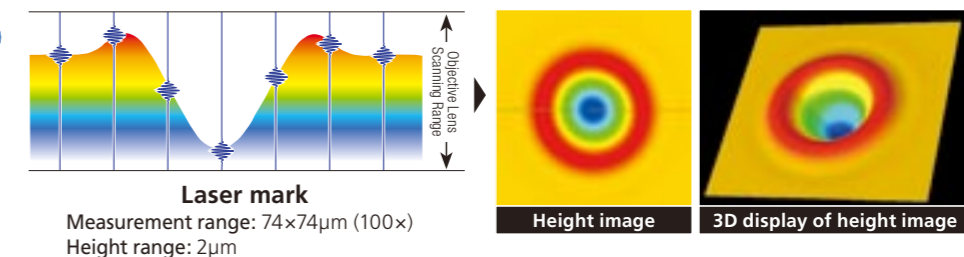
### 2 Focal position is determined with high precision from the interference waveform

The brightness of the interference is highest at the focal position (0-order interference position). The two beam interference objective lens is moved gradually by a piezo mechanism, and the position of greatest brightness is detected simultaneously and with ultra precision by all of the imaging elements.



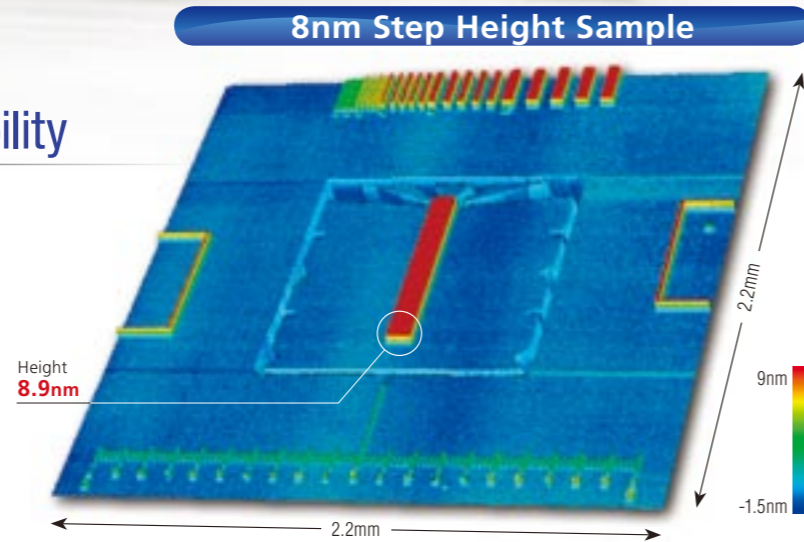
### 3 Height information mapping

The focal position information acquired by each imaging element is mapped, and the surface profile of the sample is depicted in pseudocolor.

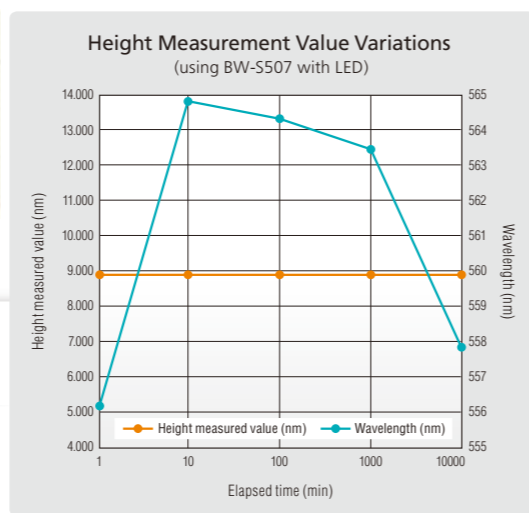
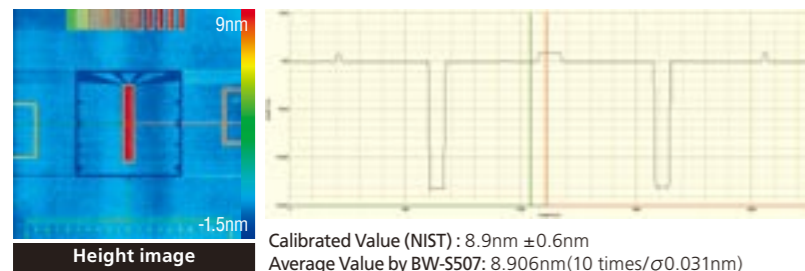


## High Traceability and Repeatability

The BW-S500/BW-D500 series is calibrated by an 8nm or 8μm VLSI Step Height Standards sample, certified by the NIST. Achieves extremely high accuracy and repeatability as a height measurement system.



## VLSI (8nm Step Height Sample)

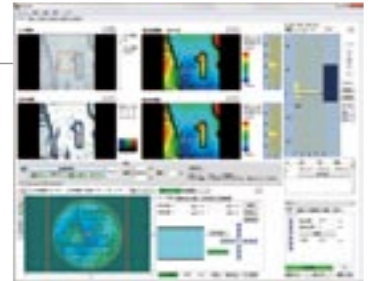


### Measured value unsusceptible to variation of central wavelength of light source

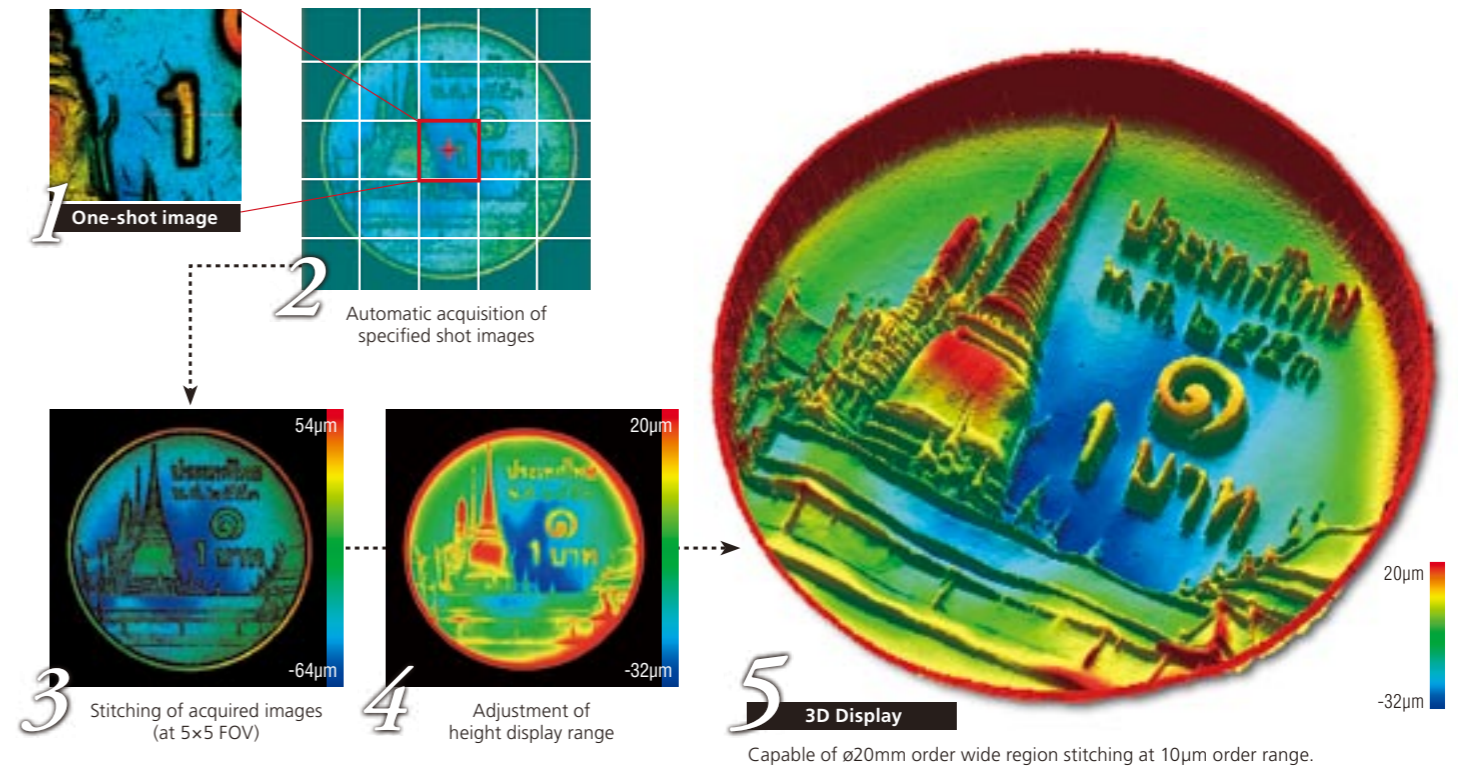
With Nikon's proprietary technology, measurement values with the BW-S500/BW-D500 series are independent of central wavelength of light source. Measurements can be done immediately after switching on illumination source.

## Wide region configuration analysis with stitching

Electric XY stage and "Digital Stylus Imager 3" software allow stitching with BW-S503/507 and BW-D503/507. Stitching can be done in both vertical and horizontal direction.



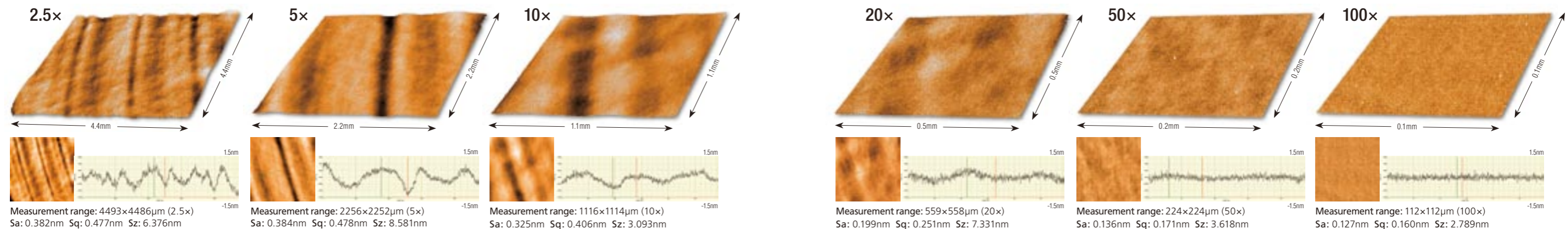
## Coin (5x5 Stitching)



## 1pm height resolution achieved at magnifications from 2.5x to 100x

Ultra high-precision allows for measurement of grade-0.1nm 3D roughness Sa from minimum magnification (4.4mm) to maximum magnification (111μm).

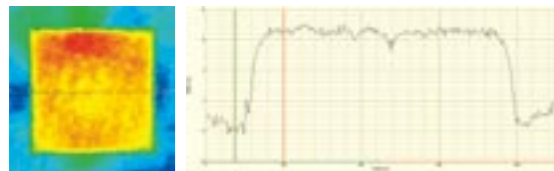
## SiC Wafer (2.5x-100x)



## Analytical software spanning basic measurement to advanced analysis

### Image Transformer

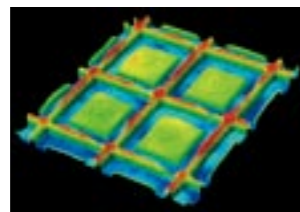
Performs automatic measurement of distance, height and angle between two points specified by the cursor, as well as two-dimensional roughness (Ra, Rq, Rz) / three-dimensional roughness (Sa, Sq, Sz)



Display of cross-section profile and measurement results at position specified on the height image

### 3DViewer

The acquired height image is displayed in 3D.



### Geometric Parameter Measurement

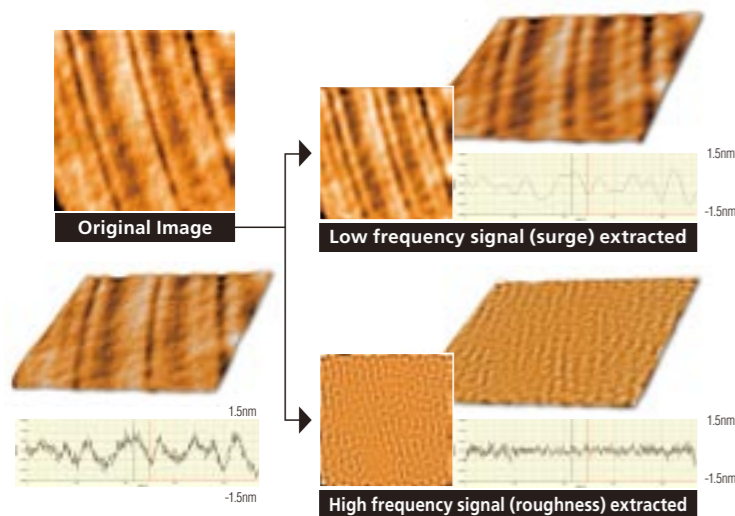
Through area and volume measurement of an irregular portion, as well as simultaneous analysis of the shapes of multiple irregular portions, uniformity and unevenness can be ascertained.



Display of the volume and area of specified indentations and protrusions

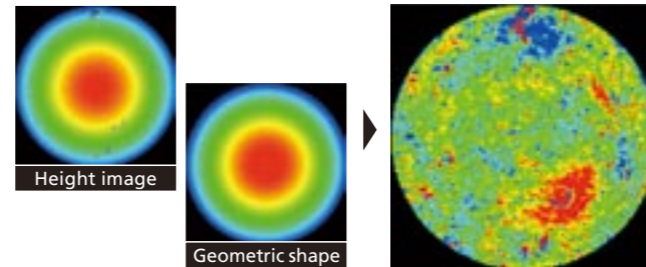
### Surface Texture Analyzer

The low frequency / high frequency components of the height image are sampled, revealing approximate surface profile and allowing roughness analysis of detailed portions.



### Zernike Polynomial Analyzer

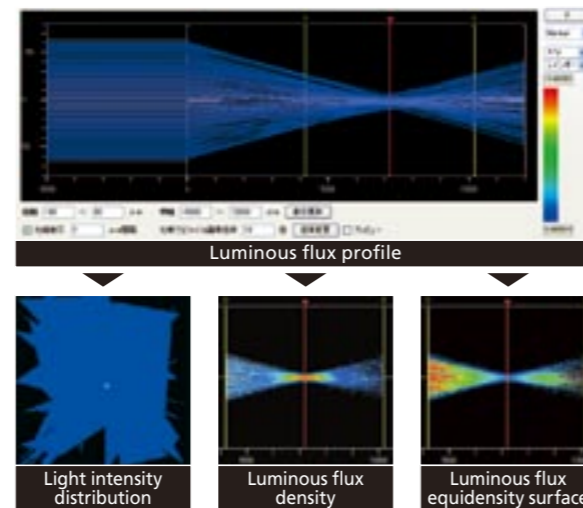
From the height image of a spherical sample, the ideal spherical surface curve (geometric shape) for the sample's form is calculated, allowing analysis of the sample's surface roughness.



The height image and the calculated geometric shape are compared, and surface roughness is detected

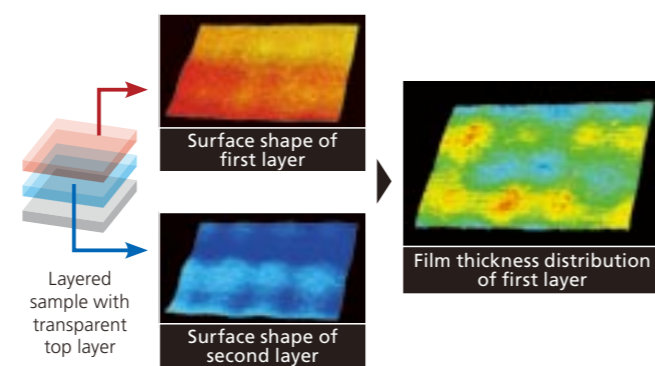
### Optical Ray Tracer

From a simulation of light rays when light is shone on the backside of a lens-shaped sample, light intensity distribution, luminous flux density, and other data can be analyzed for the specified cross section.



### Layer Thickness Analyzer

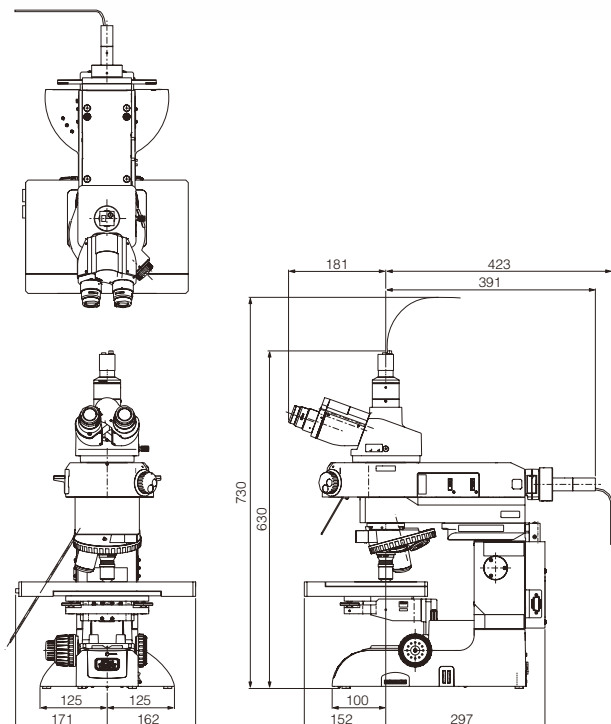
Analysis of transparent films can be performed to ascertain the surface shape of each layer and investigate the film thickness distribution. Measurement of multiple layers is possible.



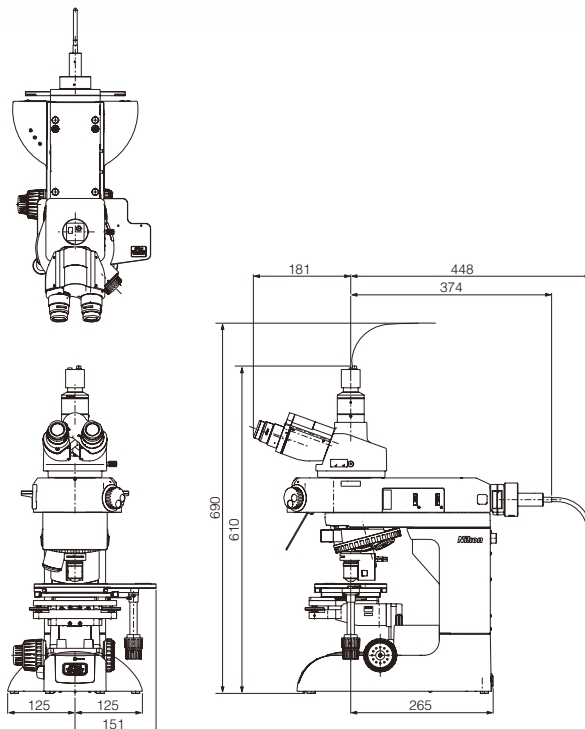
	BW-S501	BW-S502	BW-S503	BW-S505	BW-S506	BW-S507	BW-D501	BW-D502	BW-D503	BW-D505	BW-D506	BW-D507
<b>Optical Microscope Unit</b>	BW-LV150N	BW-FMA	BW-LV150N	BW-FMA	BW-LV150N	BW-FMA	BW-LV150N	BW-FMA	BW-LV150N	BW-FMA	BW-LV150N	BW-FMA
<b>Piezo Driven</b>	Objective lens driven		Nosepiece driven		Objective lens driven		Nosepiece driven		Objective lens driven		Nosepiece driven	
<b>Piezo Scanning Range</b>	100µm						100µm					
<b>Z Axis</b>	Manual	Electric (standard stroke 20mm)		Manual	Electric (standard stroke 20mm)		Manual	Electric (standard stroke 20mm)		Manual	Electric (standard stroke 20mm)	
<b>XY Axis</b>	Manual		Electric (standard travel range 130×85mm)		Manual		Electric (standard travel range 130×85mm)		Manual		Electric (standard travel range 130×85mm)	
<b>Computer</b>	High-performance specifications for BW											
<b>Monitor</b>	TFT 27" monitor											
<b>Software</b>	Bridgelements®											
<b>Imaging Camera</b>	CMOS USB 3.0 camera						High-speed camera					
<b>Number of Pixels</b>	2046×2046, 1022×1022 (selectable via software)						510 × 510					
<b>Objective Lens</b>	Two beam interference objective lens (2.5×, 5×, 10×, 20×, 50×, 100×)											
<b>Observation and Measurement Range (Two Beam Interference Objective Lens 1 Field of View)</b>												
	2.5×	5×	10×	20×	50×	100×	2.5×	5×	10×	20×	50×	100×
<b>Horizontal (H) µm</b>	4448	2224	1112	556	222	111	2015	1007	503	251	100	50
<b>Vertical (V) µm</b>	4448	2224	1112	556	222	111	2015	1007	503	251	100	50
<b>Working Distance (mm)</b>	10.3	9.3	7.4	4.7	3.4	2.0	10.3	9.3	7.4	4.7	3.4	2.0
<b>Numerical Aperture (NA)</b>	0.075	0.13	0.3	0.4	0.55	0.7	0.075	0.13	0.3	0.4	0.55	0.7
<b>Focal Depth (µm)</b>	48.5	16.2	3.03	1.71	0.90	0.56	48.5	16.2	3.03	1.71	0.90	0.56
<b>Pixel Resolution (µm)</b>	2046×2046		1022×1022		2046×2046		1022×1022		2046×2046		1022×1022	
	2.18	1.09	0.55	0.28	0.11	0.06	3.96	1.98	0.99	0.50	0.20	0.10
	4.36	2.18	1.09	0.55	0.22	0.11						
<b>Optical Resolution (µm)</b>	4.56	2.63	1.14	0.86	0.63	0.49	4.56	2.63	1.14	0.86	0.63	0.49
<b>Measurement Optical System</b>	White light interferometry											
<b>Algorithmically-specified Height Resolution</b>	1µm (0.001nm)											
<b>Effective Height Resolution (Environmental Noise)</b>	15µm (0.015nm) *When anti-vibration table is in environment not exceeding Vibration Criterion VC-C											
<b>Step Measurement Reproducibility</b>	○: 8nm (8µm step measurement) *When anti-vibration table is in environment not exceeding Vibration Criterion VC-C											
<b>Height Measurement Time (1 Field of View, 10µm Scanning)</b>	2046×2046		1022×1022		2046×2046		1022×1022		2046×2046		1022×1022	
	38 seconds		16 seconds		4 seconds		4 seconds		4 seconds		4 seconds	
<b>Height Measurement Range</b>	90µm		Lower of objective lens working distance or 20mm		90µm		Lower of objective lens working distance or 20mm		90µm		Lower of objective lens working distance or 20mm	
<b>Correction</b>	Plane Term Correction, Quartic Term Correction											
<b>Digital Enlargement</b>	1/100 sub-pixel processing											
<b>Roughness Measurement</b>	2-dimensional roughness (Ra, Rq, Rz), 3-dimensional roughness (Sa, Sq, Sz)											
<b>Profile Display</b>	Cursor measurement of height, distance, and angle between two points; measurement of approximate circle radius of location specified in the profile											
<b>Output</b>	Output of processed images and roughness indices to an Excel file											
<b>Automatic Processing</b>	Automatic processing of multiple height images											
<b>Three Dimensional Display</b>	With MS Direct X											
<b>Other Analysis Software (Optional)</b>	Geometric Parameter Measurement, Zernike Polynomial Analyzer, Optical Ray Tracer, Surface Texture Analyzer, Layer Thickness Analyzer, Reference Surface Correction, Hole Shape Analyzer											
<b>Height Calibration</b>	Standard step sample (optional) made by VLSI Standards Inc.											
<b>Anti-vibration Mechanism (Optional)</b>	Active vibration isolation table or passive vibration isolation table											
<b>Power Source</b>	100-240±10%VAC											
<b>Installation Space</b>	Approx. 1800(W) × 700(D) × 1600(H) mm											
<b>Dimensions/Weight</b>	Microscope Unit: Approx. 500(W) × 560(D) × 700(H) mm / Approx. 23 kg Computer: Approx. 173(W) × 471(D) × 414(H) mm / Approx. 20kg											

### Dimensions

**BW-S507**



**BW-D501**



Specifications and equipment are subject to change without any notice or obligation on the part of the manufacturer. March 2014 ©2014 NIKON CORPORATION

N.B. Export of the products\* in this catalog is controlled under the Japanese Foreign Exchange and Foreign Trade Law. Appropriate export procedures shall be required in case of export from Japan.

\*Products: Hardware and its technical information (including software)



**WARNING**

TO ENSURE CORRECT USAGE, READ THE CORRESPONDING MANUALS CAREFULLY BEFORE USING THE EQUIPMENT.



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